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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/081,338	02/22/2002	Jia-Fam Wong	B-4506 619547-1	9829

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EXAMINER

DI GRAZIO, JEANNE A

ART UNIT	PAPER NUMBER
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2871

DATE MAILED: 10/21/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/081,338

Applicant(s)

WONG, JIA-FAM

Examiner

Jeanne A. Di Grazio

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 21 July 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-18 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-18 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 22 February 2002 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892) 4) ☐ Interview Summary (PTO-413) Paper No(s). _____
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) ☐ Notice of Informal Patent Application (PTO-152)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____ 6) ☐ Other: _____

DETAILED ACTION

Priority

Priority to Taiwan Patent Application No. 90107642 (March 30, 2001) is claimed.

Response to Arguments

Applicant's arguments filed July 21, 2003 have been fully considered but they are not persuasive.

I. In response to applicant's argument that Suzuki et al. (US 6,043,145) is nonanalogous art, it has been held that a prior art reference must either be in the field of applicant's endeavor or, if not, then be reasonably pertinent to the particular problem with which the applicant was concerned, in order to be relied upon as a basis for rejection of the claimed invention. See *In re Oetiker*, 977 F.2d 1443, 24 USPQ2d 1443 (Fed. Cir. 1992).

In this case, contrary to Applicant's assertion that Suzuki "relates to a **technical area totally different** (emphasis in original) from that of the present application" (Page 3), Suzuki relates a method for making a multi-layer wiring structure and Applicant is essentially claiming a method of forming through holes in resist layers (methods of forming connections among several layers in a wiring structure).

Therefore, at least for the above reason, Suzuki et al., is reasonably pertinent to the particular problem with which Applicant was / is concerned.

II. Applicant's comment that "[c]omparing the figures of Suzuki et al. with the figures of the present application, there is almost nothing in common between these two inventions, except that both have many different layers" (Page 4), is not relevant to what is claimed by Applicant.

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III. Concerning Applicant's comment regarding the etching of insulating films, a resist is used to etch contact holes through the insulating layers (Col. 8, Lines 39-67).

IV. Applicant's assertion that Kurauchi et al. (US 6,323,921 B1) "does not disclose a structure in which **both** (emphasis in original) the color filter and the black matrix are formed on the TFT array substrate" (Page 5), is not correct. Applicant's attention is respectfully drawn to Figure 5c and as described in the Kurauchi patent:

"A third embodiment of a liquid crystal display device according to this invention will now be described with reference to FIGS. 4A and 4B, and FIGS. 5A, 5B and 5C. The liquid crystal display device of this embodiment is a color type active matrix liquid crystal display device, and is adapted so that color filters composed of colored layers are provided on the matrix substrate. The plan view of the matrix substrate of the liquid crystal display device of this embodiment is shown in FIG. 4A, and the plan view in the case where colored layers are formed on the matrix substrate is shown in FIG. 4B. In addition, cross sectional views when cut along cutting lines X1-X1', cutting lines X2-X2', cutting lines X3-X3' shown in FIG. 4A are respectively shown in FIGS. 5A, 5B and 5C.

The matrix substrate is adapted so that gate electrodes 24 and gate lines (scanning lines) 25 are formed on a transparent substrate 32, and signal lines 31 are formed in a direction substantially perpendicular to the gate lines 25. The regions encompassed by the gate lines 25 and the signal lines 31 respectively serve as pixel regions. Respective the same pixel trains are covered by respective the same colored layers, wherein the colored layers are disposed in a manner to take stripe pattern in order of the colored layer 6a of red (R), the colored layer 7b of green (G), and the colored layer 8c of blue (B).

Moreover, pixel electrodes 28 are formed through colored layers on respective pixel regions, and these pixel electrodes 28 are connected to respective metal layers 29b serving as the source region or the drain region of TFT through-holes 23 provided at the colored layers (see FIGS. 5A, 5B, 5C)." (Col. 8, Lines 17-47).

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Furthermore, it is to be noted that black matrices are formed by the overlap of color filters and Figure 6 (Prior Art) of Kurauchi, illustrates three different groups of pixels (pixel regions) where an area of each different pixel region is covered by at least two of the first, second, and third photoresist (color filter) layers as claimed in the independent claims (1, 7, and 13) as claimed by Applicant.

V. Taking the combination of references of Suzuki and Kurauchi together (or Kurauchi in view of Suzuki), and for that matter taking Kurauchi alone, the current claims 1, 7, and 13 are obvious in view of these references for the above reasons.

One of ordinary skill in the art at the time the invention was made would have had a reason, suggestion, and motivation to combine the teachings of Kurauchi with that of Suzuki (or to take Kurauchi alone) for a multi-layer structure having the recited elements of independent claims 1, 7, and 13 at least for a high opening ratio as specifically taught in Kurauchi (Col. 4, Lines 60-62).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1, 4, 7, 10, 13, and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Suzuki et al. (US 145) in view of Kurauchi et al. (US '921 B1).

Per claims 1 and 7: Suzuki has the steps of forming a wiring pattern for a multi layer wiring structure on a substrate, forming a first insulating layer over the wiring pattern, forming a

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second insulating layer over a wiring layer, and forming a third insulating layer over a wiring layer (See Figure 5D). Suzuki has pixel areas covered by the multiple insulating layers. In Suzuki, the insulating layers are etched (Col. 6, Lines 21-37) such that the insulating layers substantially function as resist layers. Suzuki furthermore has the structure defined by the method (Figure 5D). Suzuki does not appear to have the step of forming a plurality of signal lines and a plurality of gate lines that cross each other and the step of forming a switching unit in each pixel area; however, Kurauchi teaches that a matrix substrate generally includes plural scanning lines and plural signal lines intersecting with each other, switching elements (thin film transistors) at the intersecting regions, and pixel electrodes (Col. 6, Lines 34-38). It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Suzuki in view of Kurauchi to form an active matrix display and for switching the active matrix display and for a high opening ratio (Kurauchi, Col. 4, Lines 60-62).

Furthermore, the Kurauchi reference in view of Suzuki, discloses in Figure 6 and Figure 5c, a color filter and black matrix arrangement on a TFT array substrate.

Per claims 4, 10, and 16: Suzuki discloses the optional method of forming a protective film or the like between a lower-layer wiring pattern and first insulating film (Col. 15, Lines 54-61). It would have been obvious to one of ordinary skill in the art at the time the invention was made to include a passivation layer between switching units and first photoresist layer for preventing contact between the switching units and first photoresist layer (Id.).

Per claim 13: Suzuki has the steps of forming a wiring pattern for a multi layer wiring structure on a substrate, forming a first insulating layer over the wiring pattern, forming a second insulating layer over a wiring layer, and forming a third insulating layer over a wiring layer (See

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Figure 5D). Suzuki has pixel areas covered by the multiple insulating layers. In Suzuki, the insulating layers are etched (Col. 6, Lines 21-37) such that the insulating layers substantially function as resist layers. Suzuki furthermore has the structure defined by the method (Figure 5D). Suzuki does not appear to have the step of forming a plurality of signal lines and a plurality of gate lines that cross each other and the step of forming a switching unit in each pixel area; however, Kurauchi teaches that a matrix substrate generally includes plural scanning lines and plural signal lines intersecting with each other, switching elements (thin film transistors) at the intersecting regions, and pixel electrodes (Col. 6, Lines 34-38). It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Suzuki in view of Kurauchi to form an active matrix display and for switching the active matrix display. First and second substrates with liquid crystal in between the substrates is common in the art (See, e.g., Kurauchi at Col. 1, Lines 14-16).

Furthermore, the Kurauchi reference in view of Suzuki, discloses in Figure 6 and Figure 5c, a color filter and black matrix arrangement on a TFT array substrate.

Claims 2, 3, 5, 6, 8, 9, 11, 14, 15, 17, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Suzuki et al. (US 145) and Kurauchi et al. (US '921 B1) in further view of Lin et al. (US '653).

Per claims 2, 8, and 14: Suzuki does not appear to address TFTs as switching units; however, Kurauchi does have TFTs as noted (Col. 6, Lines 34-38). It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Suzuki in view of Kurauchi because TFTs are commonly used as switching devices. Suzuki, as can be seen in at least Figure 5D, illustrates at least a through hole that pierces through three insulating layers and

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the at least through hole exposes a section of a wiring pattern (62) as can also be seen in Figure 5D. Suzuki does not appear to specify that the drain electrode is exposed; however, Lin uses a back-etch method to expose drain electrodes through photoresist layers [See, ABS]. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Suzuki in view of Lin to facilitate connections through multiple layers and to reduce the number of necessary connections.

Per claims 3, 6, 9, 12, 15, and 18: Suzuki discloses the depositing of a conductive material to cover the insulating films (Col. 14, Lines 60-64). It would have been obvious to one of ordinary skill in the art at the time the invention was made to include a conductive layer to fill in connecting holes and to cover the insulating layers (Col. 14, Lines 60-64).

Per claims 5, 11, and 17: Because Suzuki discloses that a protective film may be formed between the lower-layer wiring pattern and first insulating film, and a through hole pierces through the three insulating layers as shown in Figure 5D, the through hole may also pierce through the protective film if so desired to facilitate connections to the wiring layer. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Suzuki in view of Lin to include a through hole through the photoresist layers and passivation film to facilitate connection to the wiring patterns.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jeanne A. Di Grazio whose telephone number is (703)305-7009. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert Kim, can be reached on (703) 305-3492. The fax phone numbers for the organization where this application or proceeding is assigned are (703)746-8741 for regular communications and (703)746-8741 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

Jeanne Andrea Di Grazio

Robert Kim, SPE

JDG


TOANTON
PRIMARY EXAMINER